

**TAKAHASHI et al**  
**U.S. National Phase of PCT/NL2004/000589**

**AMENDMENTS TO THE ABSTRACT**

Please insert the Abstract of the Disclosure which is on the attached sheet.

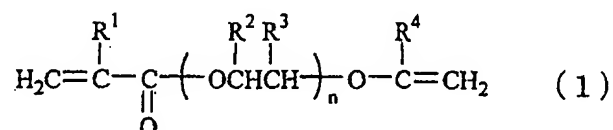
## ABSTRACT OF THE DISCLOSURE

The invention relates to a radiation-curable liquid resin composition comprising:

(A) 20-90 wt% of a urethane (meth)acrylate oligomer, and

(B) 1-35 wt% of

a monomer shown by the following formula (1),



wherein R<sup>1</sup> represents a hydrogen atom or a methyl group, R<sup>2</sup> and R<sup>3</sup> individually represent a hydrogen atom or an alkyl group having 1-4 carbon atoms, R<sup>4</sup> represents a hydrogen atom or a methyl group, and n represents an integer of 1-6, or

a monomer including a hydroxyl group.